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#24 Drawings

PATENT
AMAT/2966/DSM/BCVD/JW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:
Rathi, et al.

Serial No.: 09/165,248

Confirmation No.: 7619

Filed: October 1, 1998

For: A Silicon Carbide Deposition for Use as a Barrier Layer and an Etch Stop

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§ Group Art Unit: 2823
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§ Examiner: G. R. Fourson, III
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Approved 6/12/03

Assistant Commissioner of Patents
Washington, D.C. 20231

Dear Sir:

CERTIFICATE OF MAILING
37 CFR 1.8
I hereby certify that this correspondence is being deposited on June 20, 2002, with the United States Postal Service as First Class Mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231.

6/20/02 Keith R. Hess
Date Signature

PROPOSED AMENDMENT TO THE DRAWINGS

Applicant proposes amendment of the drawings as described below and request permission to provide substitute drawings incorporating the amendments for reasons discussed below.

IN THE DRAWINGS

Applicants propose amendment of the drawings to correct errors noted subsequent to filing the application. Applicants have submitted the proposed corrections marked in red on the attached copy of the respective original drawings filed in the application. The proposed corrections conform the drawings to the written